Special Issue

Novel Plasma Science, Technology, and Medicine

Message from the Guest Editor

Plasma is an ionised gas, used in the production of microelectronics for decades. In the last decade or so, plasma has emerged as an appealing alternative to existing technologies, because of its potential in intermittent operation, decentralised deployment, and compatibility with renewable electricity. Recent developments demonstrate the tremendous advances in plasma applications for N2 fixation, CO2 and N2O conversion, dry reforming of CH4, etc. Besides, plasma is also an invaluable tool in medicine, actively researched as an anti-microbial, anti-cancer, wound healing and dental agent. We welcome manuscripts on all aspects of plasma research: from developing plasma power supplies and reactors to process optimization, from optical analyses to medicinal plasma studies, with both applied and fundamental science discoveries Keywords

- atmospheric pressure plasma
- plasma medicine
- sustainability
- plasma nitrogen fixation
- plasma DRM
- plasma for microelectronics

Guest Editor

Dr. Yury Gorbanev

Research Group PLASMANT, Department of Chemistry, University of Antwerp, Universiteitsplein 1, 2610 Wilrijk, Belgium

Deadline for manuscript submissions

closed (30 June 2022)



Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



mdpi.com/si/91189

Applied Sciences Editorial Office MDPI, Grosspeteranlage 5 4052 Basel, Switzerland Tel: +41 61 683 77 34 applsci@mdpi.com

mdpi.com/journal/applsci





Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

Prof. Dr. Giulio Nicola Cerullo

Dipartimento di Fisica, Politecnico di Milano, Piazza L. da Vinci 32, 20133 Milano, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, CAPlus / SciFinder, and other databases.

Journal Rank:

JCR - Q2 (Engineering, Multidisciplinary) / CiteScore - Q1 (General Engineering)

